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— 国際調査報告書

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- (54) Title: POLYETHYLENE TEREPHTHALATE FOR MOLDING AND PROCESS FOR PRODUCING THE SAME
- (54) 発明の名称: 成形用ポリエチレンテレフタレートおよびその製造方法
- (57) Abstract: A process for producing polyethylene terephthalate for molding which has a reduced cyclic trimer content. The process for producing polyethylene terephthalate for molding comprises (1) a condensation step in which bis(2-hydroxyethyl) terephthalate having an ion content of 10 ppm or lower and an acid value of 30 mg-KOH/g or lower is condensed to form an oligomer having an average degree of polymerization of 4 to 10, (2) a melt polymerization step in which the oligomer is melt-polymerized to obtain a prepolymer having an intrinsic viscosity of 0.50 to 0.65, and (3) a solid-phase polymerization step in which pellets of the prepolymer are crystallized and then polymerized at 190 to 230°C by solid-phase polymerization to produce polyethylene terephthalate having an intrinsic viscosity of 0.65 or higher. Also provided is polyethylene terephthalate for molding which has been obtained by the process and has specific properties.
- (57) 要約: 本発明は、環状三量体の含有量の少ない成形用ポリエチレンテレフタレートを製造する方法を提供することを目的とする。本発明は、(1)イオン含有量が10ppm以下、酸価が30mgKOH/g以下であるビス(2-ヒドロキシエチル)テレフタレートを縮合させて平均重合度4~10のオリゴマーとする縮合工程、(2)該オリゴマーを溶融重合させて固有粘度0.50~0.65のプレポリマーとする溶融重合工程、および(3)該プレポリマーのペレットを結晶化させてから190~230℃の温度で固相重合させ、固有粘度が0.65以上であるポリエチレンテレフタレートとする固相重合工程、からなる成形用ポリエチレンテレフタレートの製造方法およびかかる方法により得られる特定の性質を有する成形用ポリエチレンテレフタレートである。



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## INTERNATIONAL SEARCH REPORT

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PCT/JP2004/014777 A. CLASSIFICATION OF SUBJECT MATTER Int.Cl<sup>7</sup> C08G63/80, C08G63/183 According to International Patent Classification (IPC) or to both national classification and IPC FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) Int.Cl<sup>7</sup> C08G63/00-63/91 Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched 1926-2004 Jitsuyo Shinan Koho Toroku Jitsuyo Shinan Koho 1994-2004 Kokai Jitsuyo Shinan Koho 1971-2004 Jitsuyo Shinan Toroku Koho 1996-2004 Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) C. DOCUMENTS CONSIDERED TO BE RELEVANT Category\* Citation of document, with indication, where appropriate, of the relevant passages Relevant to claim No. Α JP 2002-47340 A (Mitsubishi Chemical Corp.), 1-12 12 February, 2002 (12.02.02), Claim 1; Par. Nos. [0015], [0041], [0042], [0049] (Family: none) Further documents are listed in the continuation of Box C. See patent family annex. Special categories of cited documents: later document published after the international filing date or priority "A" date and not in conflict with the application but cited to understand the principle or theory underlying the invention document defining the general state of the art which is not considered to be of particular relevance "E" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive earlier application or patent but published on or after the international filing date step when the document is taken alone "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other document of particular relevance; the claimed invention cannot be special reason (as specified) considered to involve an inventive step when the document is "O" document referring to an oral disclosure, use, exhibition or other means combined with one or more other such documents, such combination document published prior to the international filing date but later than being obvious to a person skilled in the art "P" the priority date claimed document member of the same patent family Date of the actual completion of the international search Date of mailing of the international search report 22 October, 2004 (22.10.04) 09 November, 2004 (09.11.04) Name and mailing address of the ISA/ Authorized officer Japanese Patent Office Telephone No. ATTACHMENT